

Clarity Grade

GEMOLOGICAL INSTITUTE

ELECTRONIC COPY

LABORATORY GROWN DIAMOND REPORT

August 14, 2024	
IGI Report Number	LG647456324
Description	LABORATORY GROWN DIAMOND
Shape and Cutting Style	OVAL BRILLIANT
Measurements	10.03 X 6.63 X 4.31 MM
GRADING RESULTS	
Carat Weight	1.81 CARAT
Color Grade	FANCY VIVID PINK

VS 1

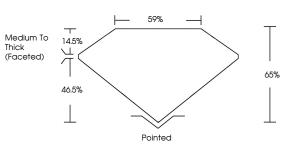
ADDITIONAL GRADING INFORMATION

Polish	EXCELLENT
Symmetry	EXCELLENT
Fluorescence	SLIGHT
Inscription(s)	1651 LG647456324

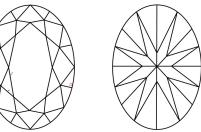
Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Indications of post-growth treatment.

LG647456324 Report verification at igi.org

PROPORTIONS



CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics. Green symbols indicate external characteristics.

1SI	LG6474563	524
UC31	LG0474563	024

Sample Image Used

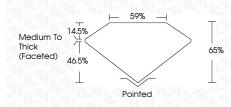
COLOR

DEF	GHIJ	Faint	Very Light	Light
	VVS ¹⁻²	VS ¹⁻²	SI ¹⁻²	1-3
Internally Flawless	Very Very Slightly Included	Very Slightly Included	Slightly	Included



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IGI Report Number	LG647456324
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Shape and Cutting	Style OVAL BRILLIANT
Measurements	10.03 X 6.63 X 4.31 MM
GRADING RESULTS	3
Carat Weight	1.81 CARAT
Color Grade	FANCY VIVID PINK
Clarity Grade	VS 1



ADDITIONAL GRADING INFORMATION

Polish EXCELLENT Symmetry EXCELLENT Fluorescence SLIGHT inscription(s) (SIC647456324 Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Indications of post-growth treatment.		
Fluorescence SLIGHT hscription(s) (15) LG647456324 Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.	Polish	EXCELLENT
nscription(s) (6) LG647456324 Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.	Symmetry	EXCELLENT
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created by Chemical Vapor Deposition (CVD) growth process.	nscription(s)	1651 LG647456324
	created by Chemical Vapo process.	or Deposition (CVD) growth





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